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		(PT	O-1449)		FILING DATE March 10, 2004				OUP	
US PATENT DOGUMENTS.										
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INITIALS	CITE NO.	Number-Kind Code2 (# known)		MM-DD-YYYY		Document		Relevant Passages or Relevant Figures Appear		
~U/		US	6,015,979	1/18/2000	Sugiura e	Sugiura et al.				
		US	6,051,849	4/18/2000	Davis et	Davis et al.				
		US	6,503,769	01/07/2003	Nakamura	Nakamura et al.				
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			AND DESCRIPTION OF THE PERSON	FOREIGNIP/	ATENT/DOCUMENTS		22.1	Z VINIGA IN CI	en ik fol a tion i	
EXAMINER'S INITIALS	CITE NO.		reign Patent Document ntry Codes-Number 4 -Kind Codes (if known)	Publication Date MM-DD-YYYY	1	Page	es, nns, Vhere vant res	Translation		
1,0		├	2000-164989	2/12/2000				Yes	No	
De		2000-164989		6/16/2000				Japan (w/ English Abstract)		
		2000-269144		9/29/2000				Japan		
								(w/ English Abstract)		
		l	2000-21789	1/21/2000		_		Japan		
								(w/ English Abstract)		
M			10-312971	11/24/1998				Japan (w/ English Abstract)		
	湖岸和原				or Title, Date Pertinent Rage					
EXAMINER'S INITIALS	CITE NO.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.								
Du		S. Nakamura et al., "Long lifetime violet inGaN/GaN/A1GaN-based semiconductor lasers", Journal of Oyo Denshi Bussel Bunkakai, Vol. 4, (1998), pp. 53-58 and 210-215.								
		Akira Usul et al., "Thick GaN Epitaxial Growth with Low Dislocation Density by Hydride Vapor Phase Epitaxy", Jpn. J. Appl. Phys. Vol. 36 (1997), pp. L899-L902.								
70		Kevin Linthicum et al., "Pendeoepitaxy of gallium nitride thin films", Applied Physics Letter, Vol. 75, No. 2, July 12, 1999, pp. 196-198.								
Dh.	Isao Kidoguchi et al., "Air-bridged lateral epitaxial overgrowth of GaN thin films", Applied Physics Letter, Vol. 76, No. 25, June 19, 2000, pp. 3768-3770.									
EXAMINER 12 DATE CONSIDERED 12 2005										

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